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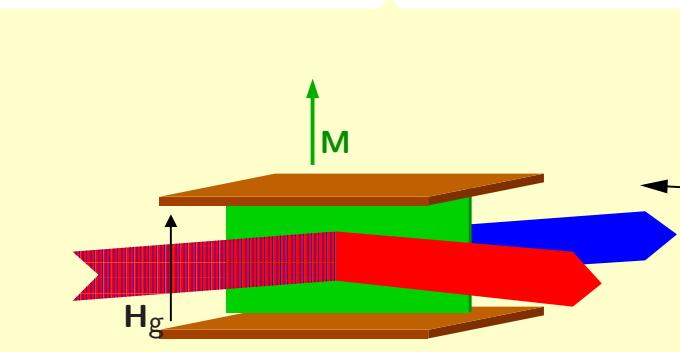
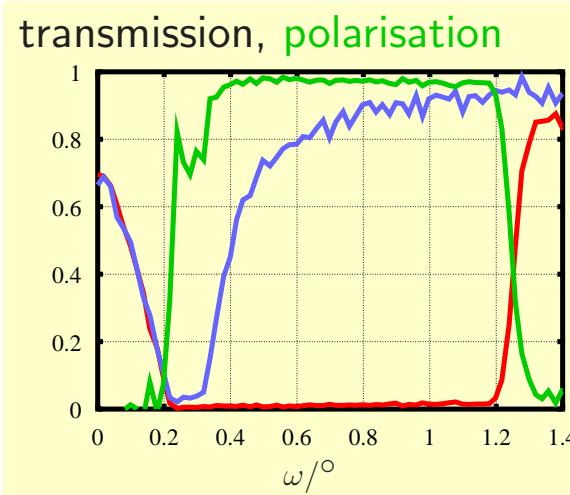
A neutron polariser based on magnetically remanent Fe/Si supermirrors

ILL, Grenoble

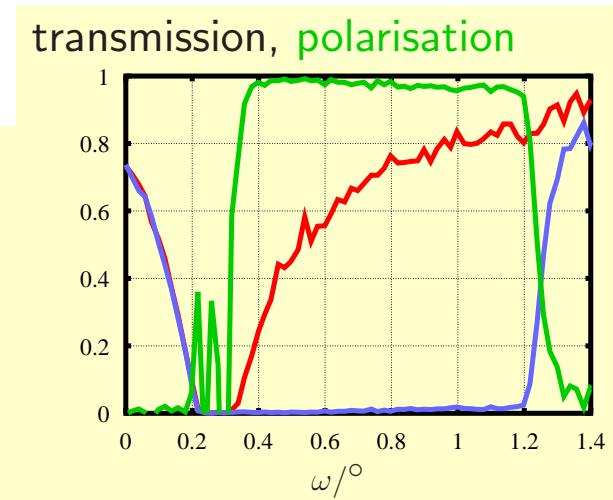
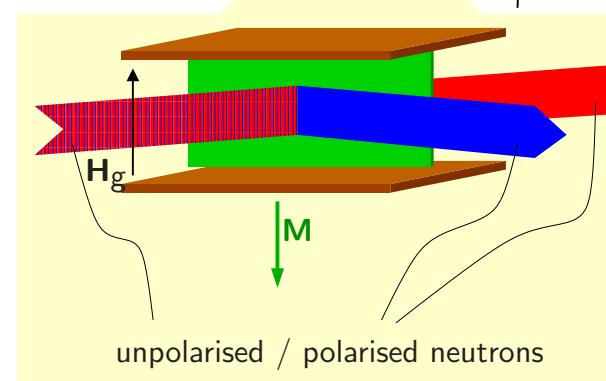
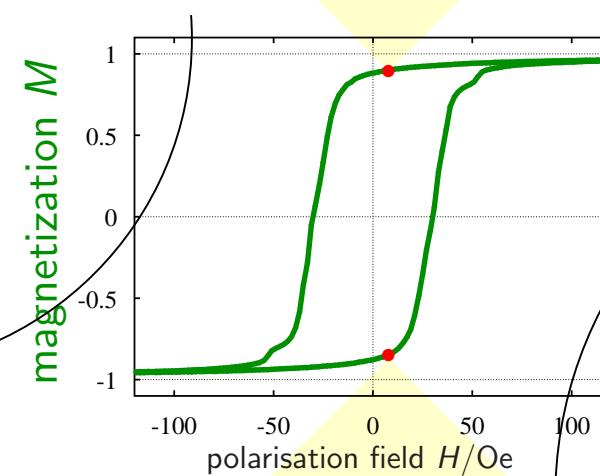
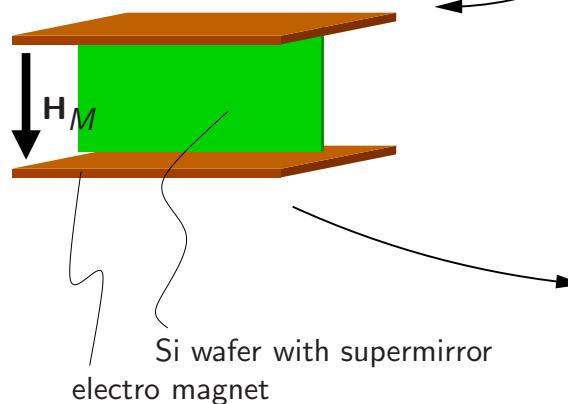
26.04.2006

remanent polariser

application principle



$H_M \approx 150 \text{ Oe}, \quad H_g < 20 \text{ Oe}$



remanent polariser material

ferromagnetic material: Fe

- might show easy axis of magnetisation
- almost matches Si for $|-\rangle$
- low absorption (required for transmission, less radiation damage)

spacer material: Si

- low potential
- matches the substrate (for transmission)
- low absorption
- can be influenced (potential and stress) by reactive sputtering

but

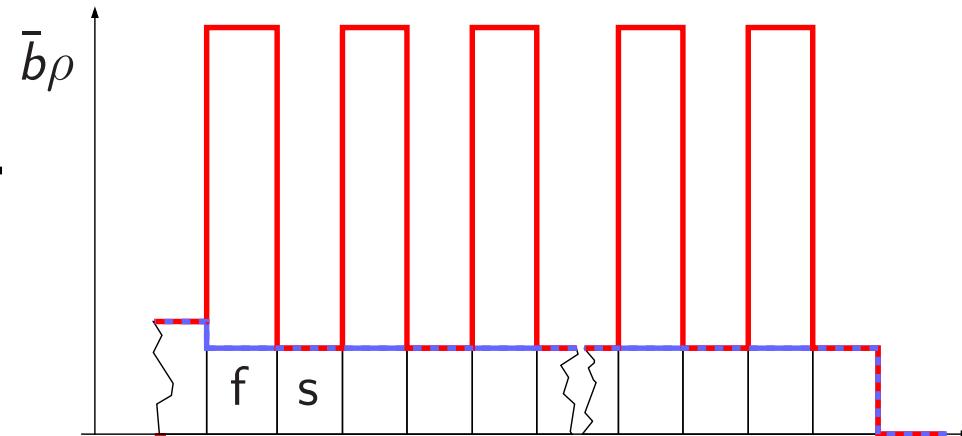
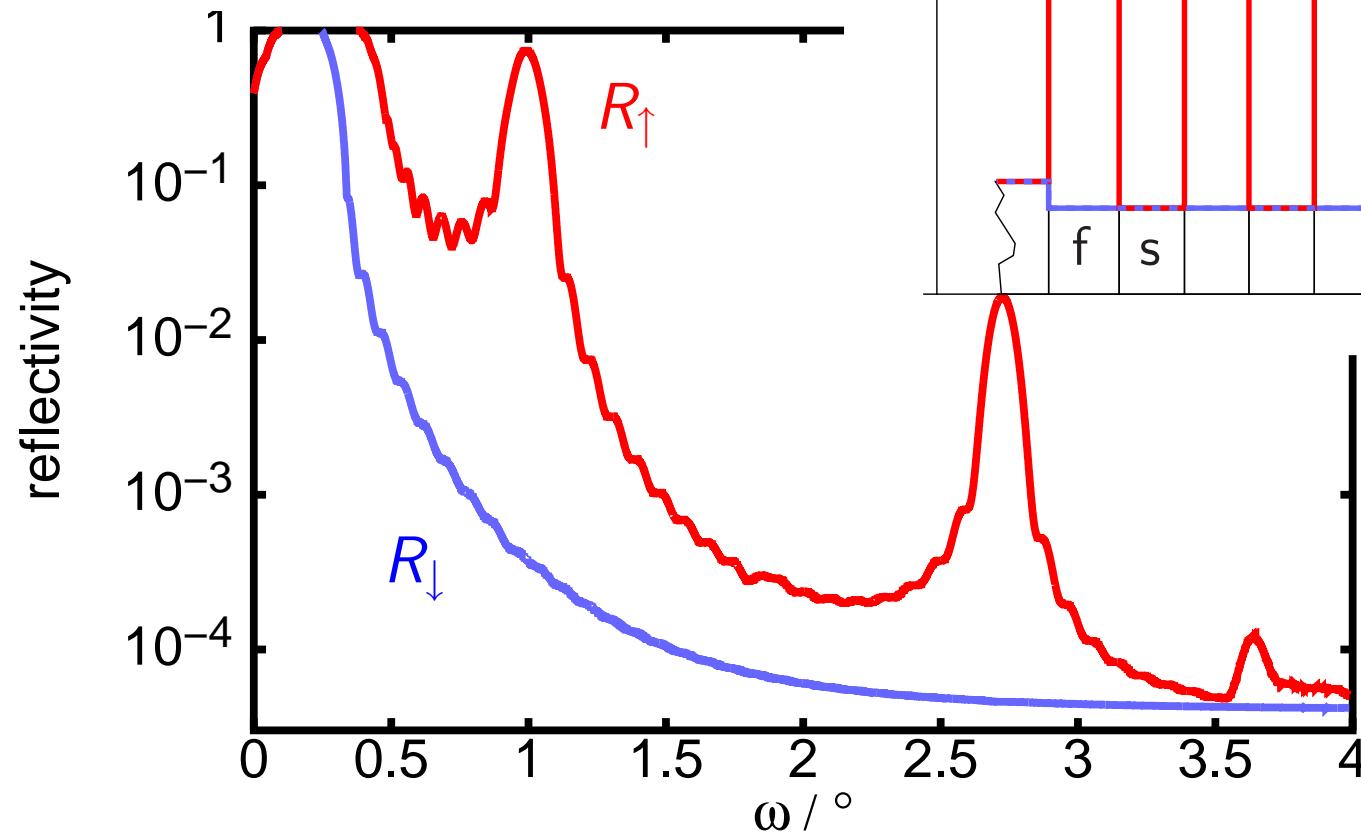
- rather low contrast for $|+\rangle$
 \Rightarrow larger number of layers required
 - total reflection for low q
-

remanent polariser

ideal ml

$$(\bar{b}_f + \bar{p}_f)\rho_f \gg \bar{b}_s\rho_s, \quad \bar{p}_s = 0, \quad \text{ferromagnet, spacer}$$

$$(\bar{b}_f - \bar{p}_f)\rho_f = \bar{b}_s\rho_s$$

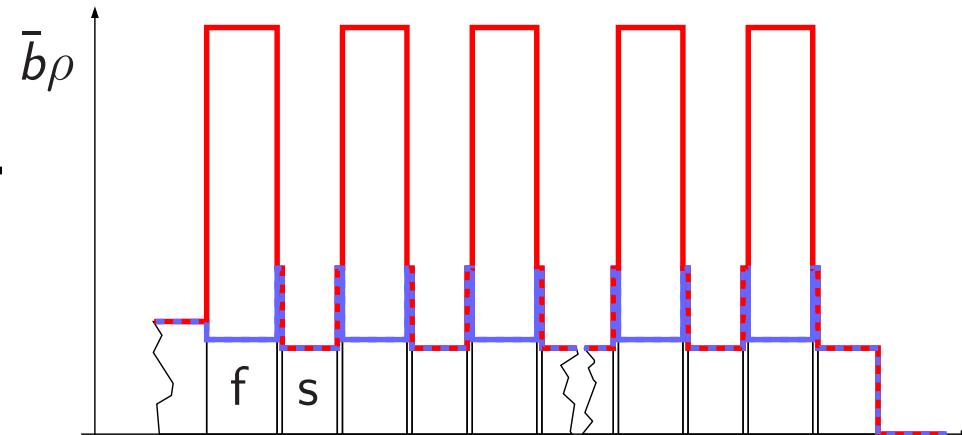
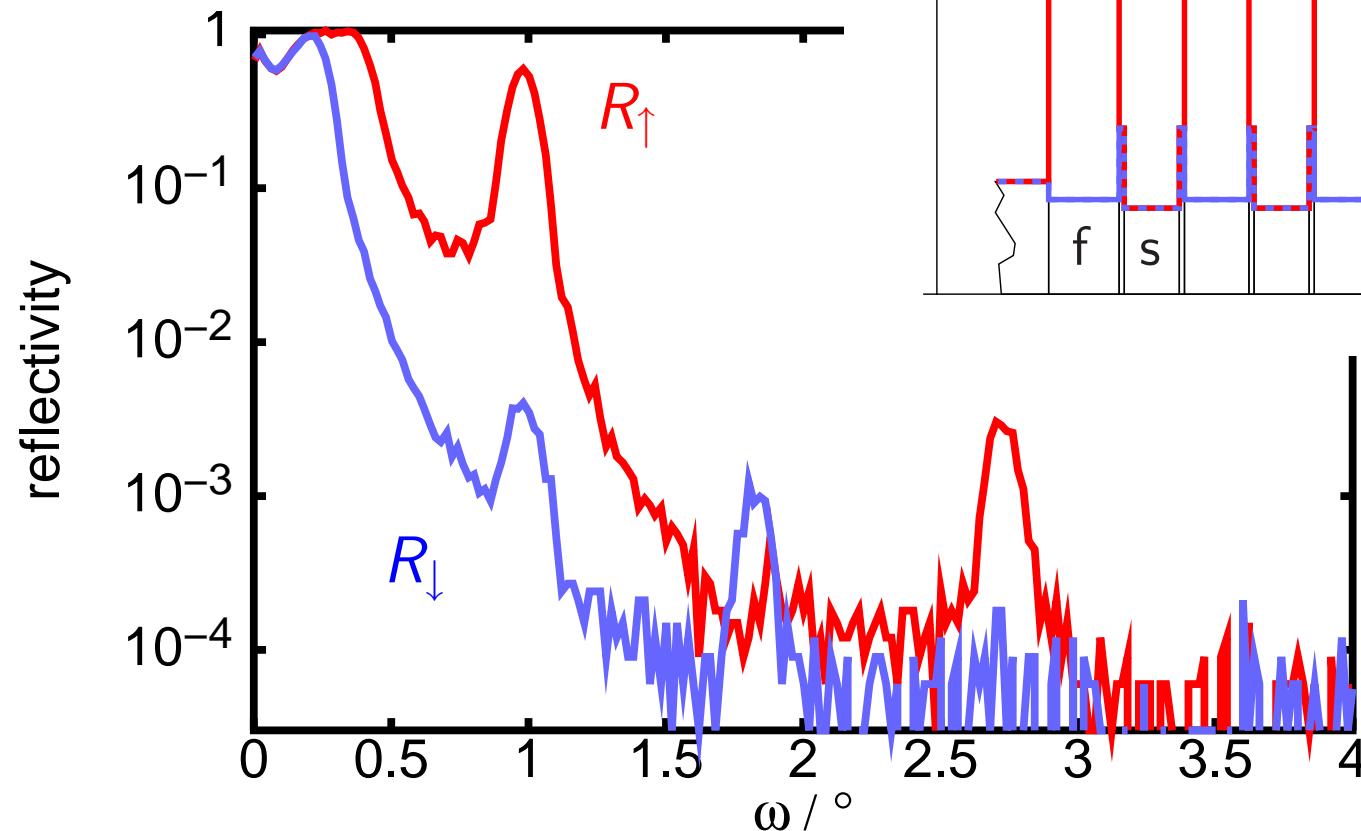


remanent polariser

real ml: Fe/Si:N:O

$$(\bar{b}_f + \bar{p}_f)\rho_f \gg \bar{b}_s\rho_s, \quad \bar{p}_s = 0, \quad \text{ferromagnet, spacer}$$

$$(\bar{b}_f - \bar{p}_f)\rho_f \approx \bar{b}_s\rho_s$$



interdiffusion
 \Rightarrow mag. dead layers
 \Rightarrow 2nd order peak

remanent polariser magnetic properties

anisotropic in-plane stress

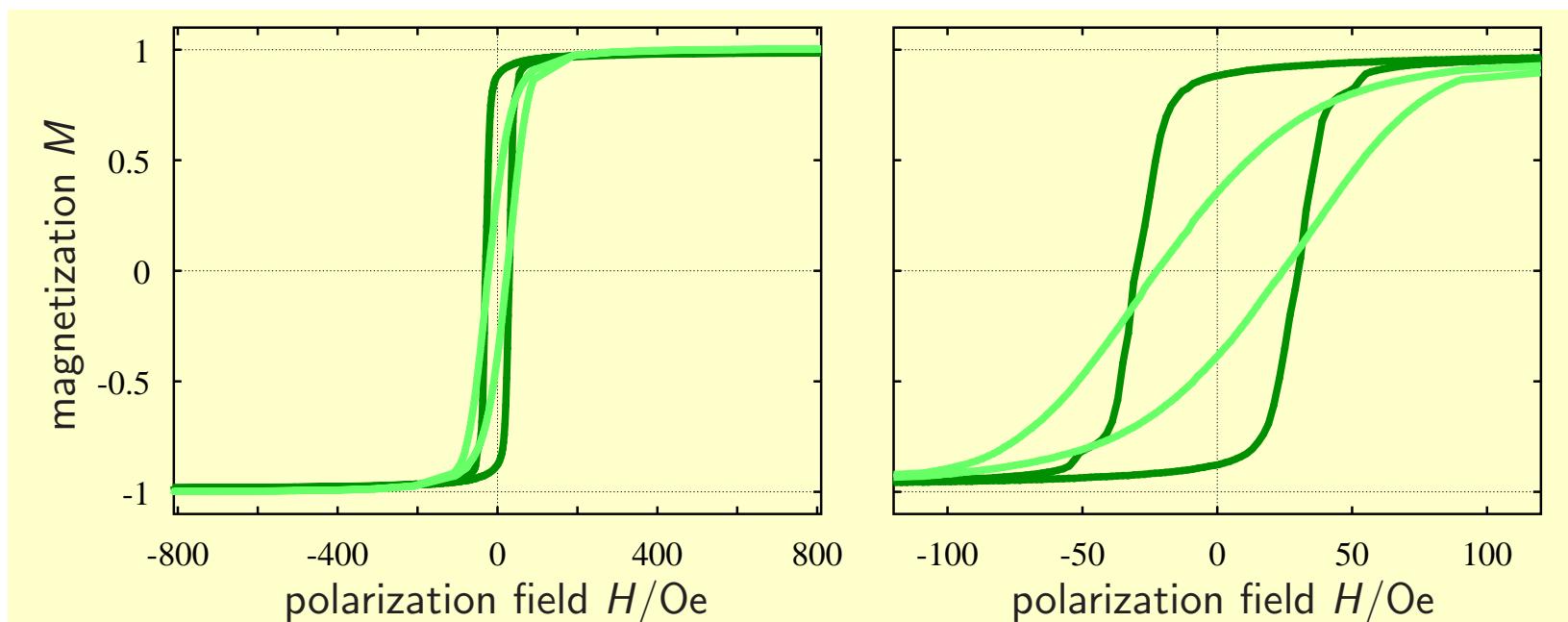
causes anisotropic magnetic properties (magnetostriiction)

reason: shape of sputter target and aperture (ca. $100 \times 400 \text{ mm}^2$)

⇒ spread of angle of incidence of sputtered atoms is anisotropic

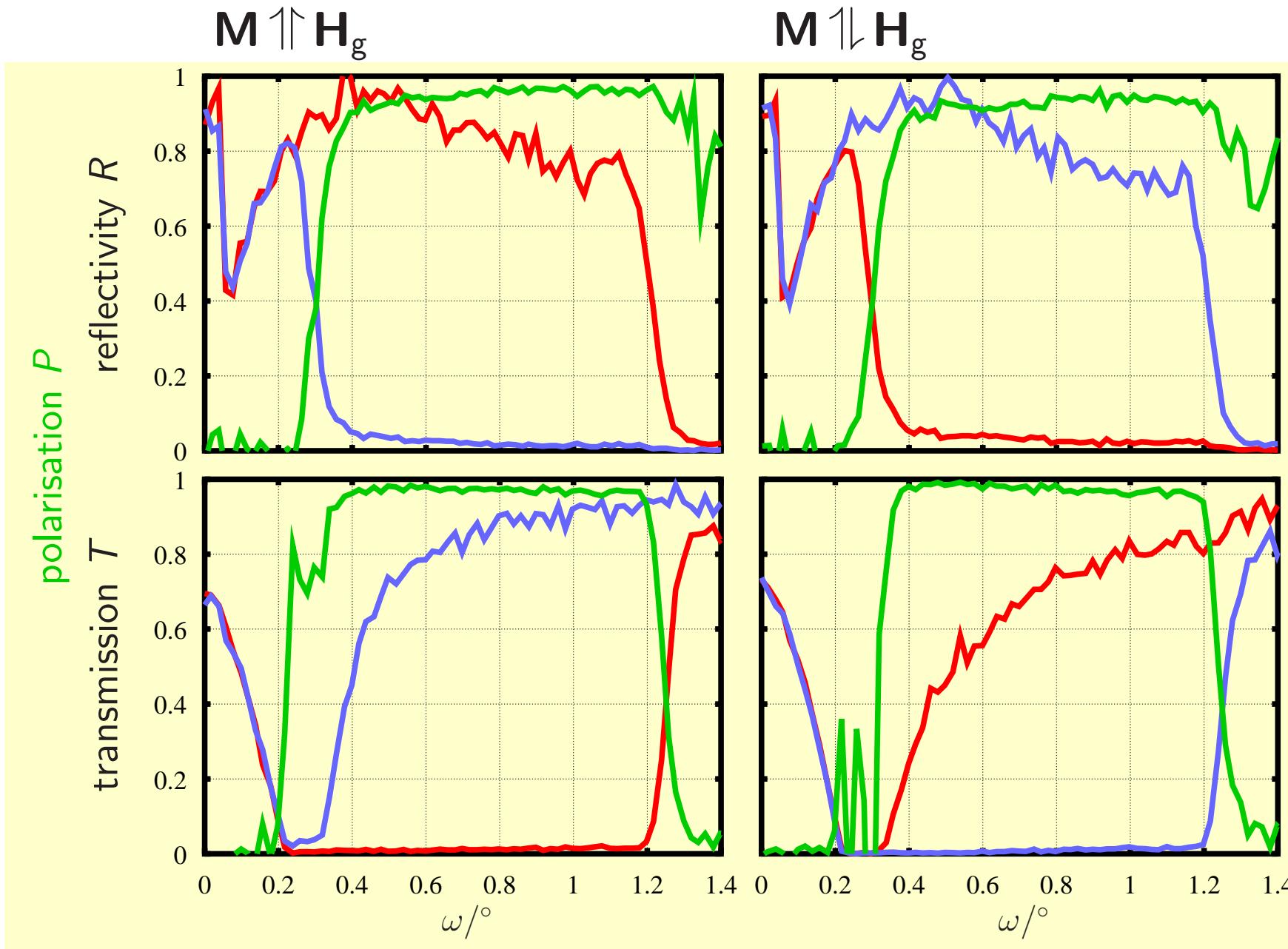
⇒ growth and thus strain formation is effected

⇒ **easy axis of magnetisation requires strained films!**



remanent polariser

performance



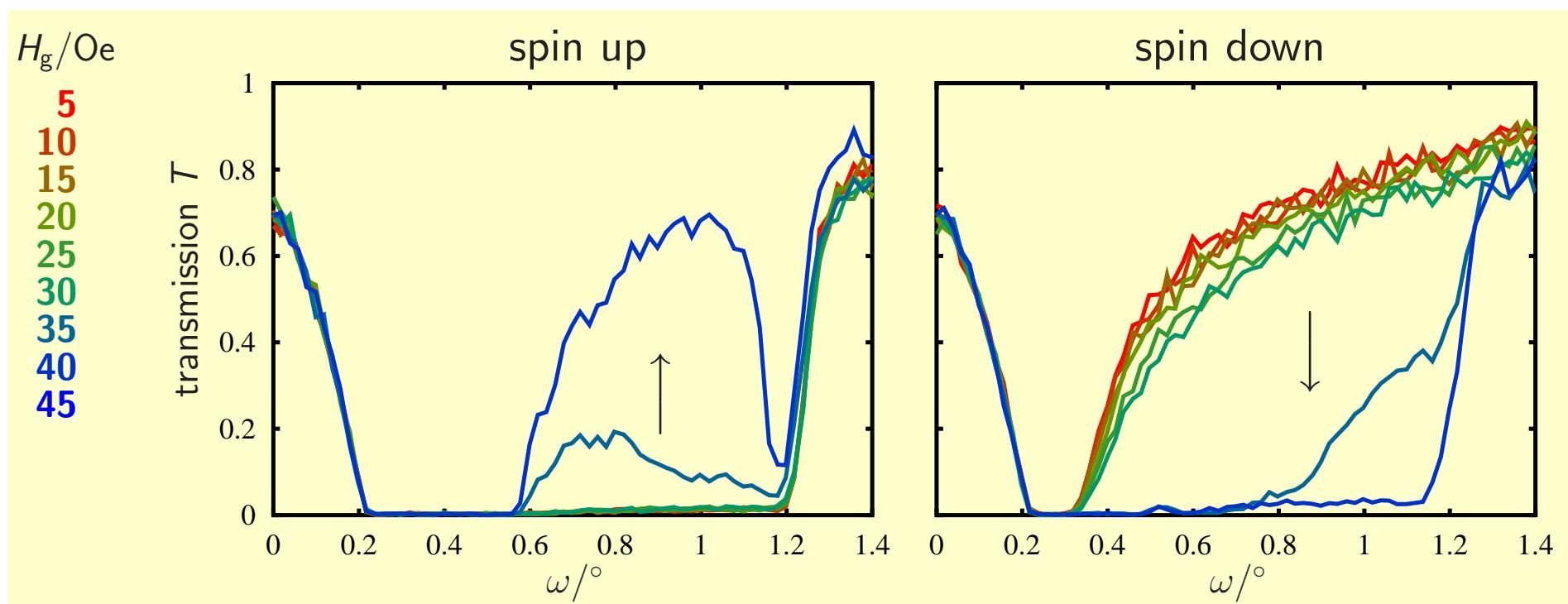
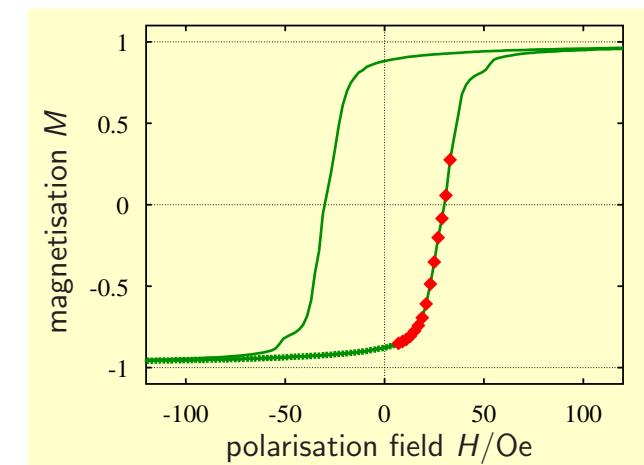
remanent polariser

H_c vs. layer thickness

saturation in $H = -700$ Oe

transmission measured in guide fields

$H_g = +5 \dots +45$ Oe



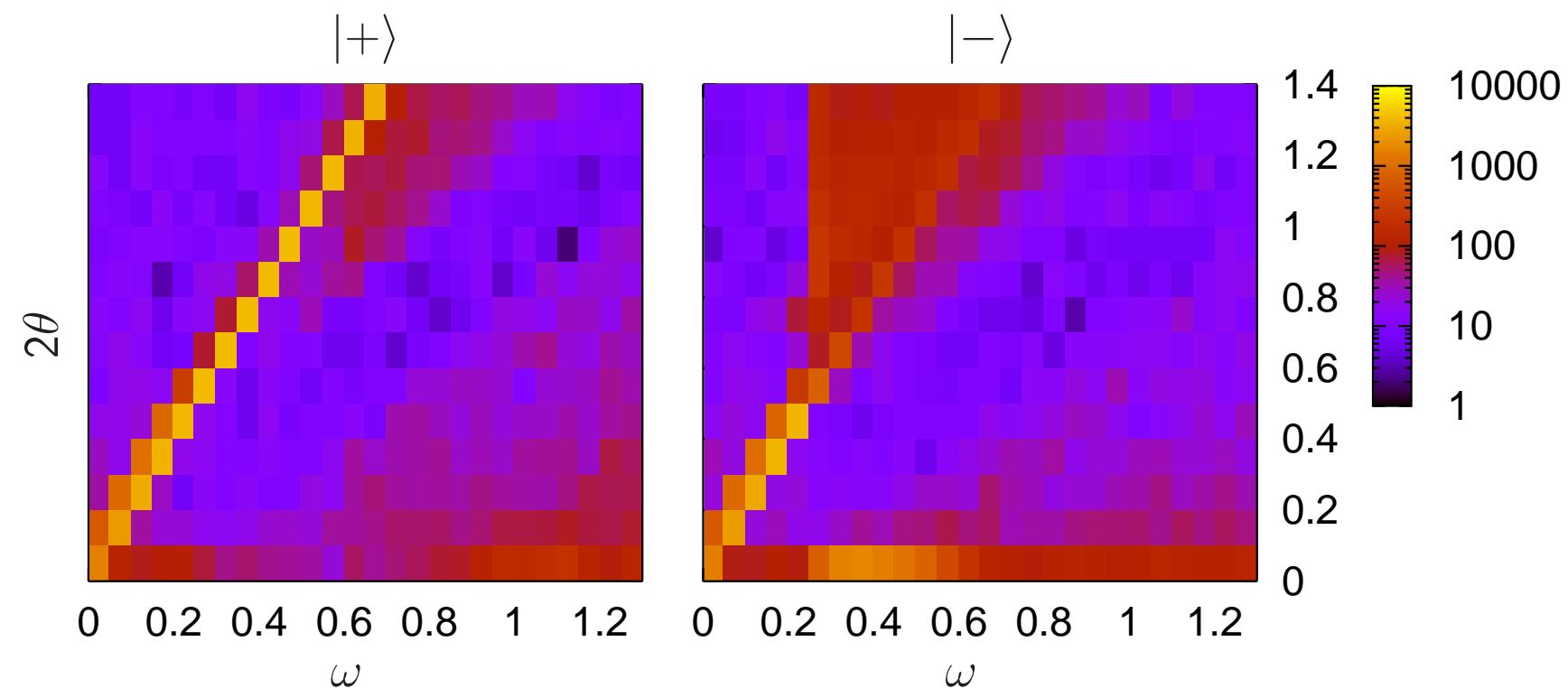
remanent polariser off-specular scattering

polarised beam, no spin analysis

Fe/Si:N:O sm, $m = 2.4$

assymmetric off-specular signal

\Rightarrow weak spin-flip scattering



remanent polariser applications: analyser

at Morpheus, Narziss (SINQ)

coating Fe / Si:N:O

$m = 3$, 599 layers

substrate Si-wafer, 0.6 mm

mirror size $200 \times 60 \text{ mm}^2$

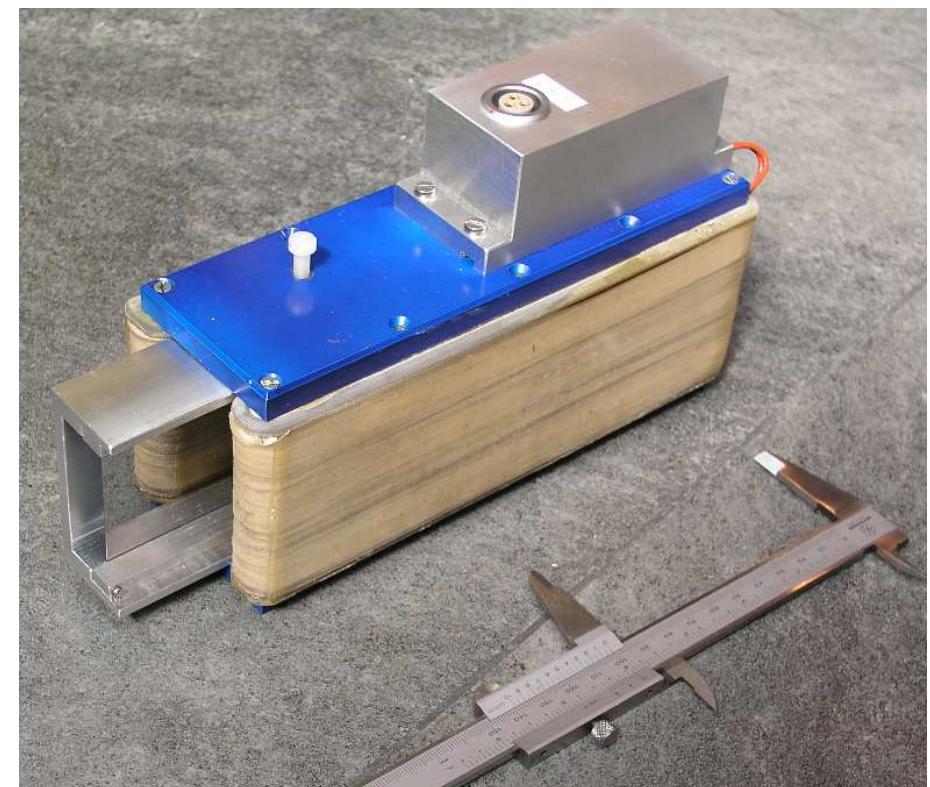
magnet size $200 \times 100 \times 100 \text{ mm}^3$

B_M 200 Oe

B_g 20 Oe

$P_{T,\uparrow\uparrow}$ > 97 %

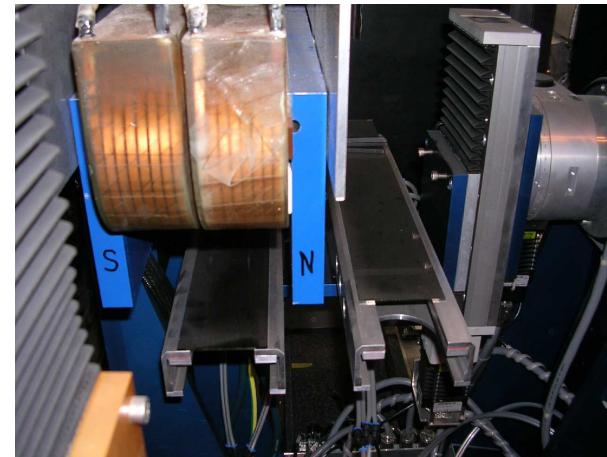
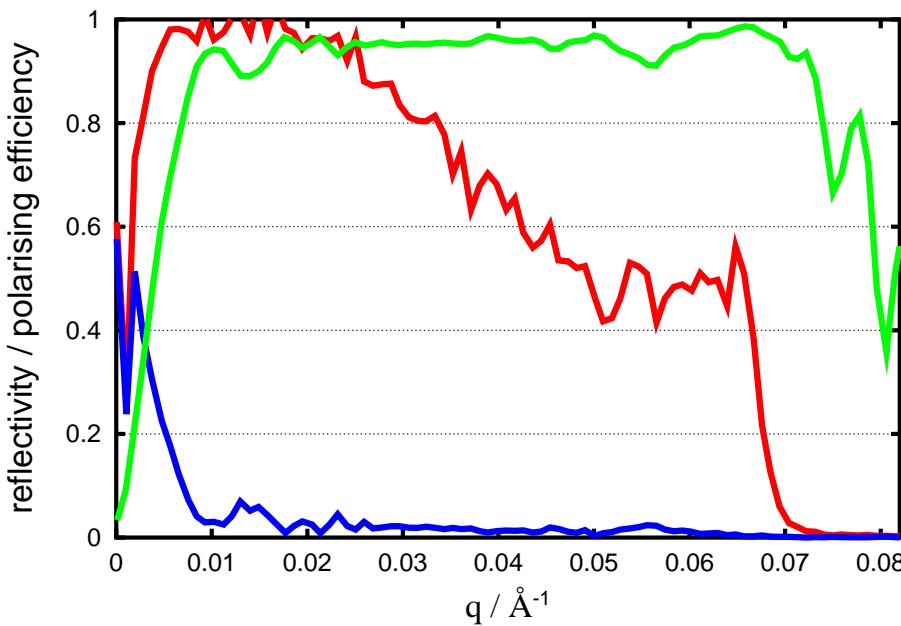
$P_{T,\downarrow\downarrow}$ > 95 %



remanent polariser at Amor (SINQ)

applications: switchable polariser

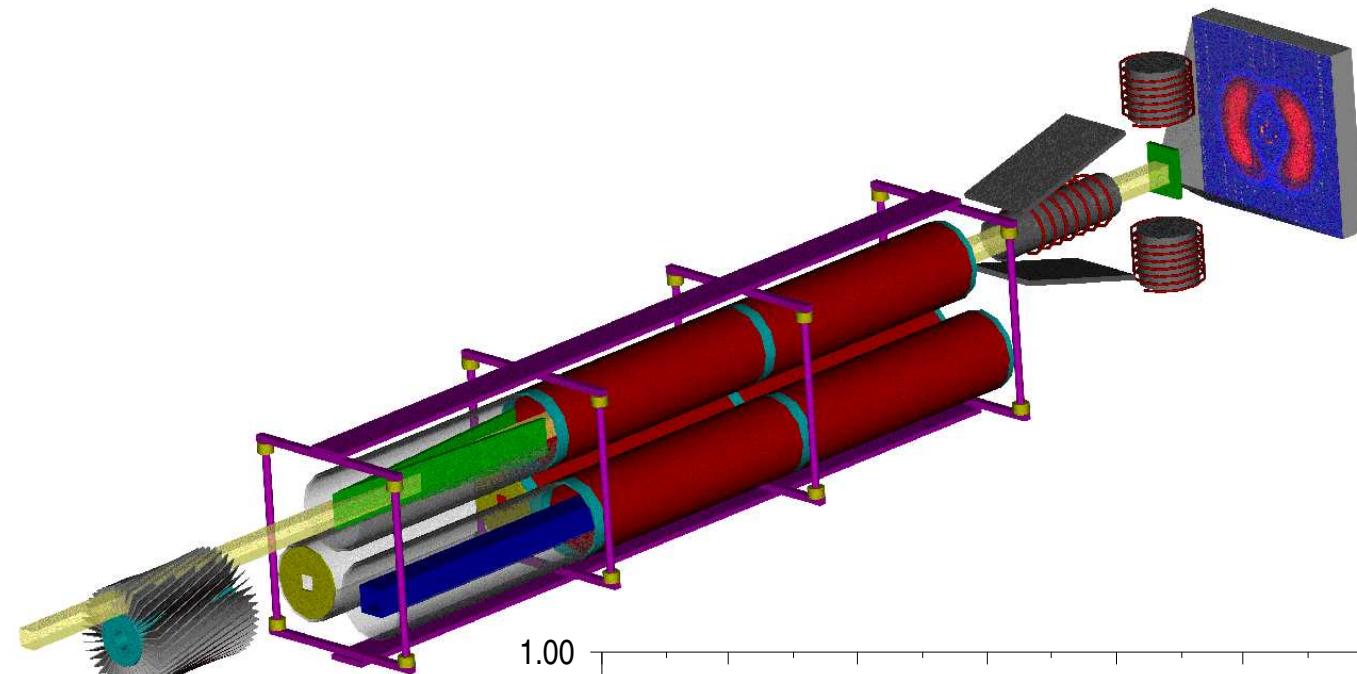
- FeCoV/TiN on glass
- operated in reflection mode
- saturation fields: ± 400 Oe
- guide field: +20 Oe



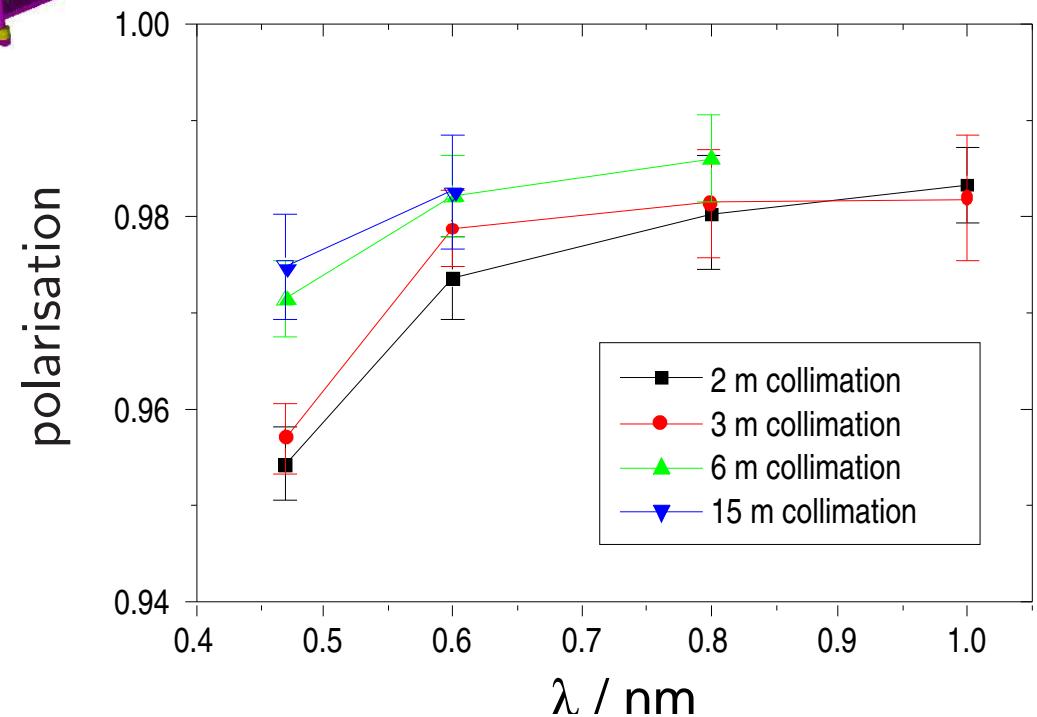
remanent polariser
at SANS I (SINQ)



applications: white beam polariser



coating Fe / Si:N:O
 $m = 2.4$, 299 layers
 substrate Si-wafer, 0.6 mm
 mirror size $200 \times 6 \text{ cm}^2$



remanent polariser conclusion:

we produced supermirrors with Fe and Si:N:O which

- polarise neutrons ($P > 95\%$ to $P = 99\%$)
- can be operated in transmission and reflection mode
- show a magnetic remanence
- thus need guide fields of 20 Oe, only
- can be operated antiparallel to the guide field

the reactive gases N₂ and O₂ in Si are needed to

- match the potentials for $|-\rangle$
- tailor strain in Fe layers (anisotropic stress), but
- keep the overall stress small

limitations:

- stress limits the number of layers $\Rightarrow m < 3$
- FeSi layer causes 2nd Bragg peak
 $\Rightarrow |-\rangle$ contamination in reflection mode